

***In the Claims***

The status of claims in the case is as follows:

We claim:

- 1     1.     [Currently amended]   A decoupling capacitor,  
2     comprising:  
  
3           a fixed resistance in series with said capacitor, said  
4           capacitor formed by a polysilicon layer and a diffusion  
5           layer, said fixed resistance formed by contacts  
6           connecting said polysilicon layer to a first voltage  
7           level buss and said diffusion layer to a second voltage  
8           level buss said capacitor connected between said first  
9           and second voltage level busses such that majority  
10          carriers accumulate at a surface of a substrate  
11          underneath a gate oxide layer without forming an  
12          inversion layer; and  
  
13          said contacts being of location and capacity for  
14          protecting surrounding circuits in the event there is a  
15          defect shorting said busses together by limiting defect  
16          current while allowing said capacitor to function at a  
17          frequency sufficiently high to suppress noise on said  
18          first and second busses to a value which achieves bus  
19          stability.

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1        2.    [Previously presented]    The decoupling capacitor of  
2        claim 1, further comprising:

3                said contacts including a first set of contacts to a  
4                first voltage and a second set of contacts to a second  
5                voltage;

6                a defect leakage current limiting path including said  
7                first set and said second sets of contacts separated by  
8                a distance optimized to cause a defect shorting said  
9                polysilicon layer to said substrate to force defect  
10               current to travel from said first set of contacts  
11               through a section of the substrate, then to the  
12               polysilicon through the defect, and then along the rest  
13               of the polysilicon layer to said second set of  
14               contacts.

1        3.    [Original]    The decoupling capacitor of claim 2,  
2        further comprising:

3                said first set of contacts and said second set of  
4                contacts determined in number and location to provide  
5                preselected minimum and maximum resistance values  
6                between said first and second sets of contacts, said  
7                minimum resistance value for achieving a preselected  
8                maximum leakage current through any defect site in said

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9 polysilicon layer, and said maximum resistance value  
10 for achieving a preselected overall decoupling RC  
11 factor sufficient for a minimum RC network bandwidth.

1 4. [Original] The decoupling capacitor of claim 3,  
2 further comprising providing said first and second sets of  
3 contacts in sufficient number to effectively achieve total  
4 contact resistance less than 10% of combined sheet  
5 resistance of said diffusion and polysilicon layers across a  
6 distance separating said first and second sets of contacts.

1 5. [Original] The decoupling capacitor of claim 2,  
2 further comprising providing N pairs of contacts in said  
3 sets of contacts and placing said first and second sets of  
4 contacts separated by a distance K sufficient to achieve a  
5 leakage limiting resistance of R and a bandwidth limiting  
6 resistance of  $R/2$ .

1 6. [Original] The decoupling capacitor of claim 2,  
2 further comprising providing a technology-dependent number  
3 of contacts selected in number sufficient to achieve total  
4 contact resistance less than 10% of combined sheet  
5 resistance of said diffusion and polysilicon layers across a  
6 distance separating said first and second sets of contacts.

1 7. [Withdrawn] A method for determining the number and  
2 position of contacts in a decoupling capacitor including a  
3 polysilicon layer and a diffusion layer, comprising:

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4 determining a maximum allowable defect current  $I$  for  
5 IDDQ testing of said capacitor;

6 determining a minimum sheet resistance  $R$  to achieve  
7 said defect current  $I$ ;

8 determining minimum distance  $K$  between first and second  
9 sets of said contacts to achieve said minimum sheet  
10 resistance  $R$ ;

11 determining number of said contacts  $N$  in said sets of  
12 contacts to provide sufficiently low contact resistance  
13 to assure said minimum sheet resistance  $R$  dominates  
14 total resistance between said first and second sets of  
15 contacts; and

16 providing in said decoupling capacitor contact sites of  
17 sufficient area to accommodate  $N$  said contacts with  
18 said first and second sets of said contacts separated  
19 by at least distance  $K$ .

1 8. [Withdrawn] A program storage device readable by a  
2 machine, tangibly embodying a program of instructions  
3 executable by a machine to perform method steps for  
4 determining the number and location of contacts in a  
5 decoupling capacitor including a polysilicon layer and a  
6 diffusion layer, said method comprising:

7 determining a maximum allowable defect current  $I$  for

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8           IDDQ testing of said capacitor;

9           determining a minimum sheet resistance R to achieve  
10          said defect current I;

11          determining minimum distance K between first and second  
12          sets of said contacts to achieve said minimum sheet  
13          resistance R;

14          determining number of said contacts N in said sets of  
15          contacts to provide sufficiently low contact resistance  
16          to assure said minimum sheet resistance R dominates  
17          total resistance between said first and second sets of  
18          contacts; and

19          defining in said decoupling capacitor contact sites of  
20          sufficient area to accommodate N said contacts with  
21          said first and second sets of said contacts separated  
22          by at least distance K.

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